

Substitute for Form 1449 A & B/PTO INFORMATION DISCLOSURE STATEMENT BY APPLICANT (use as many sheets as necessary)				Complete if Known	
				Application Number	10/804,144
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				First Named Inventor	Hiroo TAKIZAWA
				Art Unit	1711
				Examiner Name	Not yet assigned - <i>Berman</i>
Sheet	1	of	1	Attorney Docket Number	Q80575

U.S. PATENT DOCUMENTS					
Examiner Initials*	Cite No. ¹	Document Number		Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document
		Number	Kind Code ² (if known)		
		US			
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FOREIGN PATENT DOCUMENTS							
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NON PATENT LITERATURE DOCUMENTS			
Examiner Initials*	Cite No. ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city, and/or country where published.	Translation ⁶
<i>AB</i>		Brian H. Cumpston et al., "Two-photon polymerization initiators for three-dimensional optical data storage and microfabrication", Nature, Vol. 398, 1999, pp. 51-54	
		Kevin D. Belfield et al., "Multiphoton-absorbing organic materials for microfabrication, emerging optical applications and non-destructive three-dimensional imaging", J. Phys. Org. Chem., Vol. 13, 2000, pp. 837-849	
		Chengde Li et al., "Two-photon microstructure-polymerization initiated by a coumarin derivative/iodonium salt system", Chem. Phys. Lett., Vol. 340, 2001, pp. 444-448	
		Kevin D. Belfield et al., "Near-IR Two-Photon Photoinitiated Polymerization Using a Fluorone/Amine Initiating System", J. Am. Chem. Soc., Vol. 122, 2000, pp. 1217-1218	
<i>AB</i>		Shoji Maruo et al., "Three-dimensional microfabrication with two-photon-absorbed photopolymerization", Opt. Lett., Vol. 22, 1997, pp. 132-134	

Examiner Signature	<i>Susan Berman</i>	Date Considered	9-26-05
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*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

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